

## INFORMATION DISCLOSURE CITATION

APPLICANT

Lukanc et al.

FILING DATE

12/11/2001

GROUP ART UNIT

1756

(Use several sheets if necessary)

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE IF APPROPRIATE
DL	A1	6,057,063	05/02/2000	Liebmann et al.	430	5	
DL	A2	5,521,031	05/28/1998	Tennant et al.	430	5	

## FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION
						YES NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

A3	U.S. Application Serial No. 09/772,577, entitled "PHASE SHIFT MASK AND SYSTEM AND METHOD FOR MAKING THE SAME" by Lukanc.

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include any copy of this form with next communication to applicant.